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## Exact Solution for Two-Color Laser Induced Photoemission from a Biased Metal Surface

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Laser-induced electron emission is essential to the development of ultrafast electron microscopes, tabletop particle accelerators and x-ray sources, and novel quantum nanocircuits [1-3]. In particular, two-color laser induced photoemission from a metal nanotip [4] provides great flexibility for the coherent control of emitted electron distribution by using the interference effect. By solving the time-dependent Schrödinger equation [5,6], we construct an exact analytical solution for nonlinear ultrafast electron emission from a dc biased metal surface illuminated by two-color laser fields. Our results reveal various emission processes, including photo-induced over-barrier emission, and tunneling emission, for different dc and laser fields, and recover the trend in the experimentally measured energy spectra [4,7]. We find a strong dc electric field not only opens up tunneling emission channels, but also introduces intense modulation to the two-color emission current. Different combinations of the dc field and phase difference of the two lasers could offer a promising method of controlling electron dynamics in ultrashort spatiotemporal scales.

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